

## Schematic Time Schedule of PSE 2014

Time	Sunday 14/09/14		Monday 14/09/15			Tuesday 14/09/16			Wednesday 14/09/17			Thursday 14/09/18				Friday 14/09/19			
	Room Zugspitze	Room Dreiterspitz	Room Richard- Strauss	Room Zugspitze	Room Olympia	Room Richard- Strauss	Room Zugspitze	Room Olympia	Room Richard- Strauss	Room Zugspitze	Room Olympia	Room Richard- Strauss	Room Zugspitze	Room Olympia	Room Dreiterspitz	Room Richard- Strauss	Room Zugspitze	Room Olympia	
08:30 – 09:15	09:00 - 12:10	09:00 - 12:10	09:00 <b>Official Opening.</b>			<b>Plenary 2</b>			<b>Plenary 4</b>			<b>Plenary 6</b>			<b>Plenary 8</b>				
09:25 – 10:55	<b>Tutorial 1</b> Fundamentals and Trends of Plasma Surface Processing	<b>Tutorial 2</b> HIPIMS Technology	<b>Opening Lecture</b>			<b>Session 07</b>  HiPIMS	<b>Session 08</b>  Nanocomposi- tes, nanostructure s	<b>Session 09</b>  Plasma- enhanced chemical vapor deposition - PECVD	<b>Session 12</b>  Physical vapor deposition - PVD	<b>Session 13</b>  Carbon- based films	<b>Session 14</b>  Advanced plasma and ion source technologies	<b>Session 18</b>  Tribological coatings	<b>Session 19</b>  Properties of technological plasmas	<b>Session 20</b>  Biofunctionali- zation of material surfaces	<b>Tutorial 3</b> (SVC C-306)  Non- Conventional Plasma Sources and Methods in Processing Technology	<b>Session 24</b>  Plasma treatment of polymers and polymerizatio n	<b>Session 25</b>  Plasma electrolytic oxidation	<b>Session 26</b>  Structure and composition	
11:05 - 12:55			<b>Session 01</b> Simulation and modelling of structure, stoichiometry and growth	<b>Session 02</b> Characterizatio n of films (optical properties, stress, ...)	<b>Session 03</b> Plasma treatment and cleaning	<b>Industrial Exhibition</b>													
	Lunch break																		
12:55 - 14:20	13:00 - 18:00	13:00 - 16:30	Lunch break				Lunch break			Lunch break			Lunch break				Closing		
14:20 - 15:05	<b>Tutorial 1</b>	<b>Tutorial 2</b>	<b>Plenary 1</b>				<b>Plenary 3</b>			<b>Plenary 5</b>			<b>Plenary 7</b>						
15:15 - 16:45	continued	continued	<b>Poster Session 1 / Foyer</b>			<b>Session 10</b>  Magnetron sputtering I	<b>Session 11</b>  Electrical and magnetic coatings	<b>Industrial Workshop:</b>  Eco-friendly Plasma Processes	<b>Poster Session 3 / Foyer</b>			<b>Poster Session 4 / Foyer</b>			<b>Tutorial 3</b>  continued				
16:45 – 18:55			<b>Session 04</b>  Optical Coatings	<b>Session 05</b>  Atmospheric pressure plasma CVD	<b>Session 06</b>  Nano films				<b>Session 15</b>  Magnetron sputtering II	<b>Session 16</b>  Protective coatings	<b>Session 17</b>  Antibacterial applications and sterilization	<b>Session 21</b>  Mechanical properties	<b>Session 22</b>  Powders and plasmas	<b>Session 23</b>  Plasma diffusion treatment					
19:00 – 22:00	18:00 - 21:00 <b>Welcome Party / Foyer</b>	19:00 <b>EJC/PISE Meeting</b> inv. Members	19:30 <b>Public Evening Lecture</b> in German			18:45 - 22:00 <b>Poster Session 2 / Foyer</b>		18:45 - 23:00 <b>Industrial Evening / Room Werdenfels</b>		19:00 - 23:00 <b>Conference Dinner, "Bayernhalle" of Garmisch-Partenkirchen Separate tickets are required!</b>									